

Artur Tuktamyshev

List of Publications by Year in descending order

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Version: 2024-02-01

22
papers

147
citations

1307366

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1199470

12
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22
all docs

22
docs citations

22
times ranked

142
citing authors

| # | ARTICLE | IF | CITATIONS |
|----|---|-----|-----------|
| 1 | Optically controlled dual-band quantum dot infrared photodetector. <i>Nanomaterials and Nanotechnology</i> , 2022, 12, 184798042210857. | 1.2 | 2 |
| 2 | Controlling the threshold voltage of a semiconductor field-effect transistor by gating its graphene gate. <i>Npj 2D Materials and Applications</i> , 2022, 6, . | 3.9 | 6 |
| 3 | Nucleation of Ga droplets self-assembly on GaAs(111)A substrates. <i>Scientific Reports</i> , 2021, 11, 6833. | 1.6 | 6 |
| 4 | Telecom-wavelength InAs QDs with low fine structure splitting grown by droplet epitaxy on GaAs(111)A vicinal substrates. <i>Applied Physics Letters</i> , 2021, 118, . | 1.5 | 12 |
| 5 | Reentrant Behavior of the Density vs. Temperature of Indium Islands on GaAs(111)A. <i>Nanomaterials</i> , 2020, 10, 1512. | 1.9 | 2 |
| 6 | High-temperature droplet epitaxy of symmetric GaAs/AlGaAs quantum dots. <i>Scientific Reports</i> , 2020, 10, 6532. | 1.6 | 22 |
| 7 | Spectral broadening in self-assembled GaAs quantum dots with narrow size distribution. <i>Journal of Applied Physics</i> , 2019, 126, . | 1.1 | 13 |
| 8 | Temperature Activated Dimensionality Crossover in the Nucleation of Quantum Dots by Droplet Epitaxy on GaAs(111)A Vicinal Substrates. <i>Scientific Reports</i> , 2019, 9, 14520. | 1.6 | 11 |
| 9 | Pseudomorphic GeSiSn, SiSn and Ge layers in strained heterostructures. <i>Nanotechnology</i> , 2018, 29, 154002. | 1.3 | 19 |
| 10 | Effect of a Stepped Si(100) Surface on the Nucleation Process of Ge Islands. <i>Russian Physics Journal</i> , 2018, 60, 1864-1870. | 0.2 | 1 |
| 11 | Formation of a Stepped Si(100) Surface and Its Effect on the Growth of Ge Islands. <i>Semiconductors</i> , 2018, 52, 390-393. | 0.2 | 0 |
| 12 | Morphology, Structure, and Optical Properties of Semiconductor Films with GeSiSn Nanoislands and Strained Layers. <i>Nanoscale Research Letters</i> , 2018, 13, 29. | 3.1 | 15 |
| 13 | Self-assembled strained GeSiSn nanoscale structures grown by MBE on Si(100). <i>Journal of Crystal Growth</i> , 2017, 457, 215-219. | 0.7 | 5 |
| 14 | Valence-band offsets in strained SiGeSn/Si layers with different tin contents. <i>Semiconductors</i> , 2017, 51, 329-334. | 0.2 | 2 |
| 15 | Splitting of frequencies of optical phonons in tensile-strained germanium layers. <i>JETP Letters</i> , 2017, 105, 327-331. | 0.4 | 15 |
| 16 | The ordering of Ge islands on a stepped Si(100) surface. <i>Journal of Physics: Conference Series</i> , 2017, 816, 012015. | 0.3 | 0 |
| 17 | Elastically strained GeSiSn layers and GeSiSn islands in multilayered periodical structures. <i>Modern Electronic Materials</i> , 2017, 3, 86-90. | 0.2 | 0 |
| 18 | Sn influence on MBE growth of GeSiSn/Si MQW. <i>Journal of Physics: Conference Series</i> , 2017, 816, 012020. | 0.3 | 3 |

| # | ARTICLE | IF | CITATIONS |
|----|--|-----|-----------|
| 19 | Growth of Epitaxial SiSn Films with High Sn Content for IR Converters. Russian Physics Journal, 2017, 60, 354-359. | 0.2 | 5 |
| 20 | Strained multilayer structures with pseudomorphic GeSiSn layers. Semiconductors, 2016, 50, 1584-1588. | 0.2 | 5 |
| 21 | Initial growth stages of Si-Ge-Sn ternary alloys grown on Si (100) by low-temperature molecular-beam epitaxy. Semiconductors, 2015, 49, 1582-1586. | 0.2 | 3 |
| 22 | Synthesis of Epitaxial Films Based on Ge-Si-Sn Materials with Ge/GeSn, Ge/GeSiSn, and GeSn/GeSiSn Heterojunctions. Russian Physics Journal, 2015, 58, 965-969. | 0.2 | 0 |